Transport Properties of Andreev Polarons in a Superconductor-Semiconductor-Superconductor Junction with Superlattice Structure

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Transport properties of a superconductor-semiconductor-superconductor (Su-Sm-Su) junction with superlattice structure are investigated. Differential resistance as a function of voltage shows oscillatory behavior under the irradiation of radio-frequency (rf) waves with the specific frequency of 1.77 GHz regardless of the superconducting materials and the junction geometries. Experimental data are quantitatively explained in terms of the coupling of superconducting quasiparticles with long-wavelength acoustic phonons indirectly excited by the rf waves. We propose that the strong coupling causes the formation of novel composite particles, Andreev polarons.

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Transport properties of superconductor-semiconductor-superconductor (Su-Sm-Su) junctions have been studied extensively from both experimental and theoretical sides. Even in the Su-Sm-Su junctions where the supercurrent does not flow, diverse phenomena found in the dynamics of correlated quasiparticles, such as multiple Andreev reflections, attract research interests [1,2]. In this Letter, we report novel composite particles, which we call Andreev polarons, formed by the strong coupling of quasiparticles with long-wavelength phonons that are indirectly excited by radio-frequency (rf) waves. Polarons have been recognized so far as the composite particles, which are formed in the normal conducting (not superconducting) materials or dielectric materials by the electron-lattice interaction such as the deformation potential due to the acoustic phonons and Coulomb interaction in ionic crystals [3]. In conventional superconducting materials, by contrast, it has been unknown that carriers other than Cooper pairs can couple with phonons although the phonon-mediated attractive interaction between electrons is famous for the origin of Cooper pairs.

Figure 1 shows the schematic cross-sectional view of our samples. GaAs/GaAsNSe superlattice (SL) structures are sandwiched between an n-GaAs layer and two Al superconducting electrodes that form an Su-Sm-Su junction. Each of the SL structures consist of two sets of GaAs(2 nm)/GaAsNSe(2 nm) layers and three sets of GaAs(1 nm)/GaAsNSe(1 nm) layers [4]. The carrier density and carrier mobility in the n-GaAs layer at room temperature are $5 \times 10^{19}$ cm$^{-3}$ and 1000 cm$^2$/V s, respectively. We prepare samples with different lengths of the n-GaAs layer ($L$), which we identify as the length of the slit between the two Al electrodes (0.5 and 1.0 $\mu$m), while the junction width ($W$) is speculated to be somewhat shorter than the designed value of 0.6 $\mu$m. We measure the differential resistance of the Su-Sm-Su junction by means of standard lock-in technique at the temperature of 45 mK under the irradiation of rf waves. Because of the impedance mismatch at the handmade loop antenna, the irradiated power of rf waves is less than ~1% of the monitored rf sweeper power. The mean free path ($\ell$) and the coherence length ($\xi_N$) in the n-GaAs layer at low temperature of 45 mK are estimated to be ~0.1 $\mu$m and ~0.3 $\mu$m, respectively.

The measurement results are shown in Fig. 2. Although we can see some features in the differential resistance characteristics without rf irradiation, the rates of variability of differential resistance are less than 10%, which are significantly small compared with those in ideal Su-Sm-Su junctions, and suggest a resistive channel be placed in parallel with the junction. The quasiparticles experience several scatterings during the travel in the n-GaAs layer ($\ell < L$), and lose the phase information of wave function.

FIG. 1. Schematic cross-sectional view of the samples. The superlattice structure consists of two GaAs(2 nm)/GaAsNSe(2 nm) layers and three GaAs(1 nm)/GaAsNSe(1 nm) layers.
Because the resistance of the n-GaAs layer shows peaks at
we can discuss the behavior of differential resistance char-
note that this voltage drop across the channel resistance of the
resistance at the interfacial resistance at the calibration formula;
the heavy black and thin red lines represent the data without rf
voltage (Vm) and the measured current (Im) using the calibration
Especially, in the case where L is longer than ~1 μm, the channel resistance of the n-GaAs layer is comparable with the
interfacial resistance at the Al/SL interfaces, and we cannot neglect the voltage drop across the n-GaAs layer in
discussing the quasiparticle dynamics. Therefore, when we
plot the differential resistance in Fig. 2, we use the voltage
difference between the two Al/SL interfaces obtained by
the calibration formula; V = Vm−RChIm. Here, Vm and
Im are the measured voltage and current, respectively, and
the resistance of the n-GaAs channel (RCh) is estimated to be
0 and 1.4 Ω for the sample with L = 0.5 and 1.0 μm.
Because the resistance of the n-GaAs channel (RCh) is
predominantly determined by the additional parallel
current channel, the procedure of our calibration can be
validated.

On the other hand, the correlation of the quasiparticle pair marginally remains in the n-GaAs layer (ξk ~ L), and
we can discuss the behavior of differential resistance character-
istics using the Andreev bound state formed in the n-GaAs layer. The differential resistance characteristics without rf
irradiation show peaks at V = ±Vpeak = ±110 μV in the two samples shown in Fig. 2. We regard Vpeak as the twofold superconducting gap voltage of Al electrodes (Vpeak = 2Δ/e) although this Vpeak value is
significantly small compared with that of bulk aluminum (2ΔAl/e = 340 μV). The energy of the Andreev bound state under zero voltage is −Δ/e, and the peaks or dips appear in the differential resistance when the supercon-
ducting gap edge of either side of Al electrodes coincides
with the Andreev bound levels [5].

Under the irradiation of rf waves (frequency, 1.77 GHz; power, −10 dBm), the differential resistance shows oscil-
latory behaviors in both of the two samples as shown in Fig. 2. The oscillations are shown only in the voltage
near Vpeak = 110 μV, and the voltage period of the oscillation varies from 25 to 15 μV, which monotonically decreases with increasing |V|. We especially note that the minimum voltage period of 15 μV just coincides
with twice the energy of the irradiated rf photons (1.77 GHz ~ 7.3 μeV).
The Su-Sm-Su junctions without SL structures do not show the oscillatory behaviors in differential resistance under the irradiation of rf waves, while we obtain almost constant resonant frequency of 1.77 GHz for the junctions with SL structures regardless of the superconducting materials (Al or Nb [6]) and the junction geometries [the length of the n-GaAs layer (L) and the junction width (W)]. Therefore, we believe that some phonon modes inherent to the SL structure are excited by the irradiated rf waves and affect the transport properties of the junction. We will discuss later details of our scenario that the excited phonons strongly couple with the quasiparticles in the Su-Sm-Su junction.

In Fig. 3, we plot the peak position of the differential resistance as functions of rf wave frequency or power for the sample with L = 0.5 μm. When we slightly change the frequency of the irradiated rf waves, the peaks of the differential resistance shift together maintaining the voltage period almost constant, and take their minima at the resonant frequency of ~1.77 GHz. The number of the observed peaks is found to decrease as the rf frequency deviates from the resonant frequency, and the oscillatory behavior totally disappears when the frequency deviation reaches ~20 MHz. The number of the peaks is also changed by rf power. With increasing rf power, new peaks appear in both higher and lower voltage regions while the voltage period of the peaks is almost constant.

First we discuss the involved phonon modes. Only acoustic modes admit such low-energy phonons that rf excitation is possible. Using the sound velocities of acoustic phonons in bulk GaAs (4500 and 2800 m/s for longitudinal and transverse mode, respectively, in (001) direction [7]), the wavelengths are estimated to be 1.6 and 2.6 μm for the longitudinal and transverse mode. These wavelengths are comparable with the length of the n-GaAs layer (L), and we consider that the standing wave of acoustic phonon mode is excited between two Al elec-
trodes by the rf irradiation. However, the acoustic phonon modes have poor coupling efficiencies with electromag-
netic waves because the electric dipole moments are

FIG. 2 (color online). Differential resistances as functions of
electrode, respectively (frequency, 1.77 GHZ; power, −10 dBm). Voltage is obtained from the measured
voltage (Vm) and the measured current (Im) using the calibration
formula V = Vm−RChIm.

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not induced in the crystals by the acoustic vibrations. Therefore, this excitation needs another phonon mode which mediates the rf photon energy to the acoustic phonon mode. This mediating phonon mode is required to be rf active and inherent to the SL structure. The most probable candidate is the interfacial phonon mode which runs along the GaAs/GaAsNSe interfaces in the SL structure. Because of the elastic boundary conditions imposed at the GaAs/GaAsNSe interfaces together with the piezoelectricity in GaAs crystals, the interfacial mode can be rf active and have the resonant frequency of 1.77 GHz, which is determined by the sizes of GaAs/GaAsNSe interfaces. Although the dispersion relations of the interfacial phonon modes are nonlinear in general, the sound velocities in the low-energy long-wavelength limit are slightly smaller than the transverse sound velocity in bulk GaAs layers [i.e., 2800 m/s in (001) direction]. Thus, the interfacial phonon mode can couple strongly with the acoustic phonon modes of the bulk n-GaAs layer because the phonon energies are close and the pseudophase matching condition can be satisfied over a certain distance. Our speculation of the indirect excitation by the mediating interfacial phonon modes is also supported by the rf frequency dependence of the peak position shown in Fig. 3(a). The slight decrease of peak positions in the vicinity of the resonant frequency suggests the frequency entrainment with a lower-energy phonon mode caused by nonlinear phonon-phonon interaction.

As a result, the superconducting quasiparticles coexist with rf-excited long-wavelength acoustic phonons between two Al electrodes. Taking the coupling with the SL structure into account, both the standing wave of the quasiparticle wave function and that of the phonon vibration are considered to be limited to the thin surface region in the n-GaAs layer, and the quasiparticle-phonon interaction is greatly enhanced due to the dimensional confinement [8–10]. For the formation of the novel composite particles, only the coexistence and the strong quasiparticle-phonon interaction are essential, and the generating mechanism of Andreev polarons is analogous to that of standard polarons under the electron-phonon interaction [11], which we outlined briefly in the following.

We consider a one-dimensional system of superconducting quasiparticles strongly coupled with a specific acoustic phonon mode vibration. For the sake of simplicity, we discuss the transport properties of the junction in voltage state using the eigenstates, which exist only under zero voltage in a rigorous sense. Assuming that quasiparticles have discrete energy levels sufficiently separated from each other, we apply Born-Oppenheimer adiabatic approximation to the energy eigenvalue problem of this coupled system, and obtain the following two equations:

\[
\left( \begin{array}{cc}
\hat{H} & \hat{\Delta} \\
\hat{\Delta}^\dagger & -\hat{H}
\end{array} \right) \left( \begin{array}{c}
u \\
u^\dagger
\end{array} \right) = \epsilon(Q) \left( \begin{array}{c}
u \\
u^\dagger
\end{array} \right).
\]

(1)

\[
-\frac{\hbar^2}{2M} \frac{\partial^2}{\partial Q^2} + \frac{M\Omega^2}{2} Q^2 + \epsilon(Q) \varphi(Q) = E \varphi(Q).
\]

(2)

Equation (1) is a Bogoliubov–de Gennes equation with a quasiparticle-lattice interaction term \(\hat{V}(x, Q)\). For a fixed value of the phonon coordinate \(Q\), we can solve Eq. (1) in principle, and obtain the discretized energy eigenvalue of the quasiparticle system \(\epsilon(Q)\) together with the wave functions of quasiparticle eigenstates \([u = u(x; Q) \text{ and } v = v(x; Q)]\). Although we predominantly apply the boundary condition of Andreev reflection at the two Al/SL interfaces, normal reflection is also admissible due to the interface barrier. Equation (2) is a Schrödinger equation for the wave function representing phonon vibration \(\varphi(Q)\), where harmonic potential is assumed and the energy of the quasiparticle system \(E\) is included in the left-hand side.

We expand the quasiparticle-lattice interaction term \(\hat{V}(x, Q)\), together with \(\epsilon(Q), u(x; Q), \text{ and } v(x; Q)\), into the power series of normalized phonon coordinate \(Q/\Lambda\) where \(\Lambda = (\hbar/M\Omega)^{1/2}\) is the characteristic length which corresponds to the amplitude of the zero-point vibration in the phonon mode with numerical multiple \(\alpha \approx 10\); i.e., \(\hat{V}(x, Q) = \hat{V}_0(x)(Q/\Lambda) + \cdots, \epsilon(Q) = \epsilon_0 + \epsilon_1(Q/\Lambda) + \cdots, \text{ and } (u, v) = (u_0, \nu_0) + (u_1, \nu_1)(Q/\Lambda) + \cdots\), respectively. It is noteworthy that the zeroth-order term of the quasiparticle-lattice interaction is omitted \([\hat{V}_0(x) = 0]\) because it has been already included in \(\hat{H}\)
and $\Delta$ in Eq. (1). Using the standard perturbation technique, we obtain the energy of the quasiparticle system as $e(Q) = e_0 - (V_i)Q/\Lambda + O(Q^2/\Lambda^2)$. Here we note that $V(x, Q)$ is a $2 \times 2$ matrix in general, and define the expectation value $<V_i>$ as $<V_i> = \int dx(u_n^0 v_0^*) V_i(x) u_0 v_0^T$. We can diagonalize the Hamiltonian in Eq. (2) with $e(Q) = e_0 - (V_i)Q/\Lambda$ by putting $Q' = Q - (V_i)/M\Omega^2\Lambda$, and obtain the energy eigenvalue of the total system, i.e., the energy of Andreev polaron as

$$E_n = e_0 - \frac{(V_i)^2}{2\hbar\Omega} + \hbar\Omega\left(n + \frac{1}{2}\right).$$

Here the quantum number $n$ can be considered as the number of the phonons which one quasiparticle is dressed with.

In Fig. 4, we show the schematic energy diagram of Andreev polarons under zero voltage together with the adiabatic potential $[M\Omega^2Q^2/2 + e(Q)]$ which the phonon mode vibration is subjected to. Because of the quasiparticle-lattice interaction, the adiabatic potential takes its minimum at a finite phonon coordinate of $Q = (V_i)/M\Omega^2\Lambda$, which is lower than the bare energy of quasiparticles ($e_0$) by $(V_i)^2/2\hbar\Omega$. The energy-level spacing of Andreev polarons is approximately equal to that of the involved phonon $\hbar\Omega$ to an accuracy of $O(Q/\Lambda)$.

In order to describe the transport properties of the junction under the voltage state, we have to obtain the occupation probabilities of the involved Andreev bound states, which are different from the equilibrium Fermi distributions in general, and calculated by Boltzmann equation self-consistently [1,2]. However, the resonant voltages where peaks or dips are shown in differential resistance characteristics can be obtained as

$$eV = 2E_n = 2\left(e_0 - \frac{(V_i)^2}{2\hbar\Omega} + \frac{\hbar\Omega}{2}\right) + 2n\hbar\Omega.$$  

Thus, with each voltage period of $\delta V = 2\hbar\Omega/e$, the differential resistance characteristics of the junction is modulated because of the novel resonant condition. We can state that the new channel concerned with the $n$th Andreev polaron level participates to the transport of the junction with each voltage period of $\delta V$.

Because the stabilization energy of the Andreev polaron is larger than the bare energy of the quasiparticle $e_0$ ($\sim \Delta$) and the zero-point energy of the excited acoustic phonon $\hbar\Omega/2$, the first term in the right-hand side of Eq. (4) is negative. From the peak position with the largest $|V|$, which corresponds to $2E_0/e$, we estimate the magnitude of quasiparticle-lattice interaction $(V_i)/\Lambda$ as large as $\sim 0.4$ meV. When the irradiated rf power is increased, the expectation value of the phonon coordinate $<Q>$ is increased, which is consistent with the appearance of new peaks shown in higher and lower voltage regions [Fig. 3(b)].

In conclusion, we investigate transport properties of a superconductor-semiconductor-superconductor junction with superlattice structure. The differential resistance is measured as a function of bias voltage which is found to oscillate under the irradiation of radio-frequency waves with a specific frequency of 1.77 GHz. This oscillatory behavior is quantitatively explained by the strong coupling of superconducting quasiparticles with long-wavelength acoustic phonon mode vibration which is indirectly excited by rf waves. We propose the resultant formation of novel composite particles, Andreev polarons.

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